TE 135 K. Jones / 01

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Atty. Docket

RENE MONSHOUWER ET AL

NL 000770

Serial No.

Filed: CONCURRENTLY

METHOD OF MEASURING ALIGNMENT OF A SUBSTRATE WITH RESPECT TO A REFERENCE ALIGNMENT MARK

Commissioner for Patents Washington, D.C. 20231

## AUTHORIZATION PURSUANT TO 37 CFR §1.136(a)(3) AND TO CHARGE DEPOSIT ACCOUNT

Sir:

The Commissioner is hereby requested and authorized to treat any concurrent or future reply in this application requiring a petition for extension of time for its timely submission, as incorporating a petition for extension of time for the appropriate length of time.

Please charge any additional fees which may now or in the future be required in this application, including extension of time fees, but excluding the issue fee unless explicitly requested to do so, and credit any overpayment, to Deposit Account No. 14-1270.

Respectfully submitted

Michael E. Marion, Reg. 32,266

Attorney

(914) 333-9641

## `NFORMATION DISCLOSURE STATEMENT TRANSMITTAL

To Commissioner For Patents

England horswith is a Form PTO 1449, required copies of documents.

Enclosed herewith is a Form PTO-1449, required copies of documents listed thereon, and a concise explanation of their relevance is described below or enclosed herewith per 37 CFR 1.97.

Application Number	
Filing Date	CONCURRENTLY
First Named Inventor	Rene Monshouwer
	et al
Group Art Unit	
Examiner Name	140
Attorney Docket Number	NI 000770
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X	considered in drafting the specification of the above- referenced application;												
X	cited in the specification of the above-referenced application;												
	previously submitted or cited in U.S. patent application(s)which are relied on for an earlier effective filing date under 35 U.S.C. 120 (no copy required); or												
	cited as an "X" or "Y" document in a foreign Patent Office search report on a foreign counter part application, a copy of which report is also enclosed;  I hereby certify that these documents were first cited in any communication with a foreign Patent Office for a counterpart foreign application not more than three (3) months ago;												
Otherwise a concise explanation of the relevance of each document is append hereto.  I hereby certify that not one of these documents was cited in any communication with a foreign Patent Office nor was any known to any individual designated in \$1.56(c) more than three (3)													
MONT	months ago.												
		SIGNATURE OF APPLICANT, ATTO	RNEY, OR AGE	NT REQURIED									
Name (Pri	int Type)	Michael E Marion,	Registratio	Registration No. (Attorney/Agent) 32,26									
Signature		Miles	Date	August 28, 2001									

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Date Considered

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Examiner